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| APPLICATION N                      | 10.     | FILING DATE | - FIRST NAMED INVENTOR | ATTORNEY DOCKET NO.      | CONFIRMATION NO. |
|------------------------------------|---------|-------------|------------------------|--------------------------|------------------|
| 10/747,619                         |         | 12/30/2003  | Jin Hyo Jung           | 040008-0307458           | 4031             |
| 909                                | 7590    | 03/07/2005  |                        | EXAMINER                 |                  |
| PILLSB                             | URY WIN | THROP, LLP  | NHU, DAVID             |                          |                  |
| P.O. BOX 10500<br>MCLEAN, VA 22102 |         |             |                        | ART UNIT                 | PAPER NUMBER     |
|                                    | ,       |             |                        | 2818                     |                  |
|                                    |         |             |                        | DATE MAIL ED: 03/07/2005 |                  |

Please find below and/or attached an Office communication concerning this application or proceeding.

|  |  |  | •  | ( )            |  |  |  |  |
|--|--|--|--|----------------|--|--|--|--|
|  |  | Application No.  | Applicant(s)   |                |  |  |  |  |
|  | 055  | 10/747,619   | JUNG, JIN HYO  |                |  |  |  |  |
|  | Office Action Summary  | Examiner   | Art Unit   |                |  |  |  |  |
|  |  | David Nhu  | 2818   |                |  |  |  |  |
| Period f   | The MAILING DATE of this communication or Reply  | appears on the cover shee  | t with the correspondence ad   | dress          |  |  |  |  |
| THE - External control | IORTENED STATUTORY PERIOD FOR REMAILING DATE OF THIS COMMUNICATION INSIGN TO THE MONTHS FOR THE MONTHS from the mailing date of this communication in period for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory per ure to reply within the set or extended period for reply will, by streply received by the Office later than three months after the med patent term adjustment. See 37 CFR 1.704(b). | N. R 1.136(a). In no event, however, ma reply within the statutory minimum o niod will apply and will expire SIX (6) atute, cause the application to becom | ay a reply be timely filed of thirty (30) days will be considered timely MONTHS from the mailing date of this co ne ABANDONED (35 U.S.C. § 133). |                |  |  |  |  |
| Status   |  |  |  |                |  |  |  |  |
| 1)[🛛   | Responsive to communication(s) filed on 3  | 0 December 2003.   |  |                |  |  |  |  |
|  |  | This action is non-final.  |  |                |  |  |  |  |
| 3)□  | Since this application is in condition for allowance except for formal matters, prosecution as to the merits is  |  |  |                |  |  |  |  |
|  | closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.  |  |  |                |  |  |  |  |
| Disposit   | ion of Claims  |  |  |                |  |  |  |  |
| 4)🛛  | ☑ Claim(s) <u>1-6</u> is/are pending in the application.   |  |  |                |  |  |  |  |
|  | 4a) Of the above claim(s) is/are withdrawn from consideration.   |  |  |                |  |  |  |  |
| 5)[  | Claim(s) is/are allowed.   |  |  |                |  |  |  |  |
| 6)🛛  | Claim(s) 1-6 is/are rejected.  |  |  |                |  |  |  |  |
| 7)   | Claim(s) is/are objected to.   |  |  |                |  |  |  |  |
| 8)□  | Claim(s) are subject to restriction and/or election requirement.   |  |  |                |  |  |  |  |
| Applicat   | ion Papers   |  |  |                |  |  |  |  |
| 9)   | The specification is objected to by the Exam   | niner.   |  |                |  |  |  |  |
| 10)[   | ☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.   |  |  |                |  |  |  |  |
|  | Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  |  |  |                |  |  |  |  |
|  | Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).   |  |  |                |  |  |  |  |
| 11)  | The oath or declaration is objected to by the  | Examiner. Note the attac   | ched Office Action or form PT  | O-152.         |  |  |  |  |
| Priority   | under 35 U.S.C. § 119  |  |  |                |  |  |  |  |
|  | Acknowledgment is made of a claim for fore All b) Some * c) None of:  1. Certified copies of the priority documents.  2. Certified copies of the priority documents.   | ents have been received.   |  |                |  |  |  |  |
|  |  |  |  | Stogo          |  |  |  |  |
|  | 3. Copies of the certified copies of the papplication from the International But   | •  | een received in this National  | Stage          |  |  |  |  |
| * ;  | See the attached detailed Office action for a  | •  | not received.  |                |  |  |  |  |
|  |  |  | Daw Da   |                |  |  |  |  |
| Attachmer  | nt(c)  |  | pour son   |                |  |  |  |  |
|  | n(s)<br>ce of References Cited (PTO-892)   | 4) $\prod$ Intervi   | iew Summary (PTO-413)  |                |  |  |  |  |
| 2) Notice  | ce of Draftsperson's Patent Drawing Review (PTO-948)   | Paper  | No(s)/Mail Date  | . 450          |  |  |  |  |
| 3) 🔯 Infor<br>Pape   | mation Disclosure Statement(s) (PTO-1449 or PTO/SB<br>er No(s)/Mail Date   | .00/   | e of Informal Patent Application (PTC:   | <i>)</i> -152) |  |  |  |  |

#### **DETAILED ACTIONS**

### **Drawings**

1. Figures 1a, 1b should be designated by a legend such as—**Prior Art**—because only that which is old is illustrated. See MPEP & 608.02(g).

## Claims Objection

2. Claim 1, "the material of the tunnel oxide layer" lacks a clear antecedent basis.

## Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 1-6 are rejected under 35 U.S.C. 102 (b) as being anticipated by Hong (5,969,384). Regarding claim 1, Hong, (see figures 2F-2H, col. 2, lines 21-67, col. 3, lines 1-67, col. 4, lines 1-44), teaches a method of fabricating a flash memory device comprising the steps of: forming a tunnel oxide layer 42a, 42b on a semiconductor substrate 30, the tunnel oxide material layer having a conduction band energy level lower than that of SiO2 (see figure 2F, col. 2, lines 57-60); forming a floating gate 44 on the tunnel oxide layer; forming an integrate dielectric layer 46 on the floating gate; forming a control gate 48 on the integrate dielectric layer; forming a gate electrode by patterning the tunnel oxide layer, the floating gate, the control gate, and the integrate dielectric layer; and forming a source/drain region 36, 38 by performing a ion implantation into the substrate using the gate electrode as a mask (see figures 2A-2C).

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Regarding claims 2-6, Hong, (see figures 1-2, col. 1-6), also teaches the tunnel oxide layer is made of one selected from the group of material with a conduction band energy level lower than that of SiO2; forming a first tunnel oxide layer 42a on the semiconductor substrate 30; forming a second tunnel oxide layer 42b on the first tunnel oxide layer 42a; wherein the first and second tunnel oxide layer are made of one selected from the group of material (SiO2) with a conduction band energy level equal or similar to that of SiO2; wherein the first tunnel oxide layer 42a is deposited more thickly than the second tunnel oxide layer 42b (see figure 2H).

# Claim Rejections - 35 USC § 102

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

6. Claims 1 are rejected under 35 U.S.C. 102(e) as being anticipated by Forbes et al (6,781,876 B2).

Regarding claim 1, Forbes, (see figures 2, 3, col. 6, lines 9-67, col. 7, lines 1-30), teaches a method of fabricating a flash memory device comprising the steps of: forming a tunnel oxide layer 225 on a semiconductor substrate 230, the tunnel oxide material layer having a conduction band energy level lower than that of SiO2 (figure 3, col. 6, lines 37-67); forming a floating gate 215 on the tunnel oxide layer; forming an integrate dielectric layer 235 on the floating gate; forming a control gate 220 on the integrate dielectric layer; forming a gate

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electrode by patterning the tunnel oxide layer, the floating gate, the control gate, and the integrate dielectric layer; and forming a source/drain region 205, 210 by performing a ion implantation into the substrate using the gate electrode as a mask (see figures 2-3).

#### Conclusion

- 7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure: Da'245, Forbes'448, Forbes'535, Nagamine'988 are cited as of interest.
- 8. A shortened statutory period for response to this action is set to expired 3 (three) months and 0 (zero) day from the date of this letter. Failure to respond within the period for response will cause the application to become abandoned(see 710.02 (b)).
- 9. Any inquiry concerning this communication on earlier communications from the examiner should be directed to David Nhu (571)272-1792. The examiner can normally be reached on Monday-Friday from 7:30 AM to 5:00 PM. The examiner's supervisor, David Nelms can be reached on (571)272-1787.

The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Information regarding the status of an application may be obtained from the patent application information retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR

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system, see <a href="http://pair-direct.uspto.gov">http://pair-direct.uspto.gov</a>. Should you have questions on access to the Private

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PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

David Nhu

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March 4, 2005